## **WEST Search History**

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DATE: Tuesday, December 07, 2004

**Hide? Set Name Query** 

**Hit Count** 

DB=USPT,EPAB,JPAB,DWPI,TDBD; PLUR=NO; OP=ADJ

L1 jp-2003268372-\$.did. or jp-2003003169-\$.did. or de-10220549-\$.did.

6

END OF SEARCH HISTORY

```
C:\Program Files\Stnexp\Queries\964650.st
chain nodes :
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7 8 9
           22 23 24
                      25
                          26
ring nodes :
   1 2 3 4 5 6
                   10 11 12 13 14 15
                                         16
                                            17
                                                 18
                                                    19
                                                        20
                                                           21
chain bonds :
   2-15 4-8 5-7 6-9 12-20 17-22 22-23 23-24 24-25 25-26
ring bonds :
   1-2 1-6 2-3 3-4 4-5 5-6 10-11 10-15 11-12 12-13 13-14
   16-17 16-21 17-18 18-19 19-20 20-21
exact/norm bonds :
   10-11 10-15 11-12
                            13-14
                      12-13
                                   14-15
                                         16-17
                                                16-21
                                                      17-18
                                                            18-19
   20-21
exact bonds :
   2-15 4-8 5-7
                 6-9 12-20 17-22 22-23
                                        23-24
                                                24-25
                                                      25-26
normalized bonds :
   1-2 1-6 2-3 3-4 4-5 5-6
```

Match level:
1:Atom 2:Atom 3:Atom 4:Atom 5:Atom 6:Atom 7:CLASS 8:CLASS 9:CLASS
10:Atom 11:Atom 12:Atom 13:Atom 14:Atom 15:Atom 16:Atom 17:Atom
18:Atom 19:Atom 20:Atom 21:Atom 22:CLASS 23:CLASS 24:CLASS 25:CLASS

```
T.4
     ANSWER 1 OF 3 CAPLUS COPYRIGHT 2004 ACS on STN
AN
     2003:750981 CAPLUS
DN
     139:268115
ED
     Entered STN: 25 Sep 2003
ΤI
     Nematic liquid crystal compositions and liquid crystal displays
IN
     Kuriyama, Takeshi
PA
     Dainippon Ink and Chemicals, Inc., Japan
     Jpn. Kokai Tokkyo Koho, 12 pp.
     CODEN: JKXXAF
DT
     Patent
LA
     Japanese
     ICM C09K019-42
IC
     ICS
         C09K019-12; C09K019-14; C09K019-20; C09K019-24; C09K019-30;
          C09K019-34; G02F001-13; G02F001-133; G02F001-139
CC
     74-13 (Radiation Chemistry, Photochemistry, and Photographic and Other
     Reprographic Processes)
     Section cross-reference(s): 75
FAN.CNT 1
     PATENT NO.
                        KIND
                               DATE
                                           APPLICATION NO.
                                                                  DATE
     ------
                        ----
                               -----
                                           -----
                                                                  -----
     JP 2003268372
                         A2
                               20030925
                                           JP 2002-76085
                                                                  20020319
PRAI JP 2002-76085
                               20020319
CLASS
 PATENT NO.
                CLASS
                       PATENT FAMILY CLASSIFICATION CODES
                       -----
 JP 2003268372
                ICM
                       C09K019-42
                ICS
                       C09K019-12; C09K019-14; C09K019-20; C09K019-24;
                       C09K019-30; C09K019-34; G02F001-13; G02F001-133;
                       G02F001-139
OS
    MARPAT 139:268115
GΙ
```

Liquid crystal compns. containing (1) I (1, n = 0-10; X1 = H, F), (2) II (R1 = 1) AΒ C2-8 alkyl, alkoxyl, alkenyl, alkenyloxy; A = 2.5-pyrimidinedyl, 2,5-pyridinedyl), and (3) III (R2-3 = (F-substituted) C1-8 alkyl, C1-8 alkoxyl, C2-8 alkenyl, C3-8 alkenyloxy; B, C, D = 1,6-C6H10, 1,6-C6H2X2X3; X2-3 = H, F, Me; Z1-2 =CO2, OCO, C2H4, OCH2, CH2O, CH:CH, CF:CF, CH:NN:CH, C.tplbond.C; m = 0, 1) and having nematic phase-isotropic liquid phase transition temperature (TN-I) 70-180° and refractive index anisotropy  $(\Delta n)$  0.06-0.30 are claimed. Also claimed is displays using the claimed liquid crystal compns. The compns. show prevented image burn and steep voltage-transmission characteristics. ST nematic liq crystal compn display; cyanophenylcyclohexane liq crystal

compn; cyanofluorophenyl alkenyl cyclohexane liq crystal compn

IT Liquid crystal displays (nematic liquid crystal compns. and liquid crystal displays free of image burn)

IT Liquid crystals

(nematic; nematic liquid crystal compns. and liquid crystal displays free of image burn)

IT 59854-97-6 59855-03-7 59855-05-9 85583-83-1 86776-50-3 86776-51-4 86776-52-5 88038-92-0 107949-21-3 107949-22-4 126702-59-8 128060-75-3 129738-34-7 129738-42-7 155041-85-3

157453-50-4 157453-54-8 184652-93-5 337366-98-0 **477557-84-9** 

RL: DEV (Device component use); TEM (Technical or engineered material use); USES (Uses)

(liquid crystal compns. containing; nematic liquid crystal compns. and liquid  $\ensuremath{\mathsf{compns}}$ 

crystal displays free of image burn)

IT 477557-84-9

RL: DEV (Device component use); TEM (Technical or engineered material use); USES (Uses)

(liquid crystal compns. containing; nematic liquid crystal compns. and liquid

crystal displays free of image burn)

RN 477557-84-9 CAPLUS

CN Benzonitrile, 4-[(trans,trans)-4'-ethenyl[1,1'-bicyclohexyl]-4-yl]-2,6-difluoro- (9CI) (CA INDEX NAME)

Relative stereochemistry.

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L4 ANSWER 2 OF 3 CAPLUS COPYRIGHT 2004 ACS on STN
```

AN 2003:17385 CAPLUS

DN 138:80812

ED Entered STN: 09 Jan 2003

TI Nematic liquid crystal compositions and liquid crystal displays (LCD) giving high-contrast images at wide temperature ranges

IN Kuriyama, Takeshi; Takeuchi, Kiyofumi

PA Dainippon Ink and Chemicals, Inc., Japan

SO Jpn. Kokai Tokkyo Koho, 8 pp.

CODEN: JKXXAF

DT Patent

LA Japanese

IC ICM C09K019-46

ICS C09K019-12; C09K019-14; C09K019-18; C09K019-20; C09K019-30; G02F001-13

CC 74-13 (Radiation Chemistry, Photochemistry, and Photographic and Other Reprographic Processes)
Section cross-reference(s): 75

FAN.CNT 1

PATENT NO. KIND DATE APPLICATION NO. DATE

PI JP 2003003169 PRAI JP 2001-189541 CLASS A2 20030108 20010622 JP 2001-189541

20010622

PATENT NO.

CLASS PATENT FAMILY CLASSIFICATION CODES

JP 2003003169

ICM C09K019-46

ICS

C09K019-12; C09K019-14; C09K019-18; C09K019-20;

C09K019-30; G02F001-13

OS MARPAT 138:80812

GΙ

$$CnH2n+1$$

$$R^{1}$$

$$R^{2}$$

$$R^{2}$$

$$R^{2}$$

$$R^{3}$$

$$R^{1}$$

$$R^{1}$$

$$R^{2}$$

$$R^{3}$$

$$R^{3}$$

$$R^{3}$$

$$R^{3}$$

$$R^{4}$$

$$R^{2}$$

$$R^{4}$$

$$R^{5}$$

$$R^{2}$$

$$R^{3}$$

$$R^{3}$$

$$R^{4}$$

$$R^{4}$$

$$R^{5}$$

$$R^{4}$$

$$R^{5}$$

$$R^$$

The compns. have nematic-isotropic transition point (TN-I) 70-180°, have refractive index anisotropy ( $\Delta n$ ) 0.06-0.30, and contain (1)  $\geq 1$  of I (X1 = H, F; l, n = 0-10) (2)  $\geq 1$  of II (R1 = C2-8 alkyl, alkoxyl, alkenyl, alkenyloxy; A = 1,4-C6H6, A1; X2-4 = H, F) and (3)  $\geq 1$  of III (R2-3 = C1-8 alkyl, C1-8 alkoxyl, C2-8 alkenyl, or C3-8 alkenyloxy optionally having fluorine substitution; B, C, D = 1,4-C6H6, A2; X5-6 = H, F, Me; Z1-2 = single bond, CO2, C2H4, CH:CH, CF:CF, C.tplbond.C; i, j = 0, 1; i + j = 1, 2). LCD comprising the compns., especially super-twisted nematic LCD of twist angle 180-270°, is also claimed.

ST nematic liq crystal compn; STN liq crystal display compn

IT Liquid crystal displays

(nematic liq crystal composition containing; nematic liquid crystal compns.

for

IT

IT

STN-LCD giving high-contrast images at wide temperature ranges) Liquid crystals

(nematic, super-twisted; nematic liquid crystal compns. for STN-LCD giving high-contrast images at wide temperature ranges)
Liquid crystals

(nematic; nematic liquid crystal compns. for STN-LCD giving high-contrast images at wide temperature ranges)

IT 39969-28-3 61203-99-4 80944-44-1 85583-83-1 86776-50-3 86776-51-4 86776-52-5 88038-92-0 107949-21-3 107949-22-4

111336-21-1 115978-59-1 123843-69-6 123843-78-7 128060-75-3 222725-48-6 330207-83-5 482373-31-9 482373-35-3 482373-36-4 482373-37-5 **482373.-38-6** 482373-39-7 RL: DEV (Device component use); TEM (Technical or engineered material use); USES (Uses) (nematic liq crystal composition containing; nematic liquid crystal compns. for STN-LCD giving high-contrast images at wide temperature ranges) IT 157453-52-6 169152-36-7 477557-84-9 482373-40-0 482373-41-1 482373-42-2 482373-43-3 RL: TEM (Technical or engineered material use); USES (Uses) (nematic liq crystal composition containing; nematic liquid crystal compns. for STN-LCD giving high-contrast images at wide temperature ranges) IT 482373-38-6 RL: DEV (Device component use); TEM (Technical or engineered material use); USES (Uses) (nematic liq crystal composition containing; nematic liquid crystal compns. for STN-LCD giving high-contrast images at wide temperature ranges) RN 482373-38-6 CAPLUS Benzonitrile, 2,6-difluoro-4-[(trans,trans)-4'-(2-propenyl)[1,1'-CN bicyclohexyl]-4-yl]- (9CI) (CA INDEX NAME)

Relative stereochemistry.

IT 477557-84-9 482373-40-0 482373-41-1 482373-43-3

RL: TEM (Technical or engineered material use); USES (Uses) (nematic liq crystal composition containing; nematic liquid crystal compns.

STN-LCD giving high-contrast images at wide temperature ranges) 477557-84-9 CAPLUS

CN Benzonitrile, 4-[(trans,trans)-4'-ethenyl[1,1'-bicyclohexyl]-4-yl]-2,6-difluoro- (9CI) (CA INDEX NAME)

Relative stereochemistry.

for

RN

RN 482373-40-0 CAPLUS

CN Benzonitrile, 2,6-difluoro-4-[(trans,trans)-4'-(1E)-1-propenyl[1,1'-bicyclohexyl]-4-yl]- (9CI) (CA INDEX NAME)

Relative stereochemistry.

Double bond geometry as shown.

RN 482373-41-1 CAPLUS

CN Benzonitrile, 4-[(trans,trans)-4'-(3-butenyl)[1,1'-bicyclohexyl]-4-yl]-2,6-difluoro- (9CI) (CA INDEX NAME)

Relative stereochemistry.

RN 482373-43-3 CAPLUS

CN Benzonitrile, 2,6-difluoro-4-[(trans,trans)-4'-(3E)-3-pentenyl[1,1'-bicyclohexyl]-4-yl]- (9CI) (CA INDEX NAME)

Relative stereochemistry.

Double bond geometry as shown.

```
ANSWER 3 OF 3 CAPLUS COPYRIGHT 2004 ACS on STN
L4
AN
     2002:924311 CAPLUS
DN
     138:13926
ED
     Entered STN: 05 Dec 2002
ΤI
     Procedure for the production of polycyclic compounds
PA
     Merck Patent Gmbh, Germany
SO
     Ger. Offen., 22 pp.
     CODEN: GWXXBX
DT
     Patent
LΑ
     German
IC
     ICM C07F013-00
         C07F003-06; C07F003-02; C07C025-18; C07C025-24; C07C013-28;
          C07C001-26; C07C255-49; C07B049-00; C07B037-04; C07D521-00
CC
     24-5 (Alicyclic Compounds)
     Section cross-reference(s): 75
FAN.CNT 1
     PATENT NO.
                        KIND
                               DATE
                                          APPLICATION NO.
                                                                DATE
                                          ------
     DE 10220549
                               20021205
                         A1
                                          DE 2002-10220549
                                                                20020508
PRAI DE 2001-10125633
                         A1
                               20010525
CLASS
 PATENT NO.
                CLASS
                       PATENT FAMILY CLASSIFICATION CODES
                       ______
 DE 10220549
                ICM
                       C07F013-00
                ICS
                       C07F003-06; C07F003-02; C07C025-18; C07C025-24;
                       C07C013-28; C07C001-26; C07C255-49; C07B049-00;
                       C07B037-04; C07D521-00
OS
    MARPAT 138:13926
GΙ
```

AB Polycyclic compds. R1AkZ1mA1EnQo(Z2A2)pR2 [R1 = H, halogen, (un)substituted alkyl; R2 = H, halogen, CN, NCS, SF5, (un)substituted

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alkyl, NH2, CO2H; A = (un) substituted 1,4-cyclohexanediyl,
      1,4-oxacyclohexanediyl, 1,4-thiacyclohexanediyl, 1,4-cyclohexenediyl,
      1,4-bicyclo[2.2.2]octanediyl, C6H4, azaphenylene; A1 = (un)substituted
      decahydronaphthalene-2,6-diyl, 4,4'-bicyclohexanediyl,
      cyclohexylethylcyclohexane-4,4'-diyl, cyclohexylethylcyclohexene-4,4'-diyl;
       A2 = A or A1; E = (un) substituted CH:CH; Z1, Z2 = CH2CH2, CH2CHF, CHFCH2,
      CHFCHF, CF2CH2, CH2CF2, CF2CHF, CHFCF2, CF2CF2, CH:CH, CF:CH, CH:CF,
      CF:CF, OCH2, CH2O, CF2O, OCF2, CO2, O2C, CHCNCH2, CH2CHCN, bond; Q =
      (un) substituted p-C6H4, azaphenylene, 1,4-cyclohexanediyl, oxa
      cyclohexane-1,4-diyl, thiacyclohexane-1,4-diyl, 1,4-cyclohexenediyl,
      bicyclo[2.2.2]octane-1,4-diyl; k, n, o = 0, 1; m, p = 0-2] were prepared by
      treating an organometallic compound R1A0kZ1mA1M [M = MgCl, MgBr, MgI, MnCl,
      MnBr, MnI, ZnCl, ZnBr, ZnI, ZnAlZlmAkR1] with XEnQo(Z2A2)pR2 [X = Cl, Br,
      I, O3S(CF2)0-10CF3] in presence of a metal catalyst. The procedure is
      used advantageously for the production of liquid crystalline compds. Thus,
      1-bromo-4-(4-propylcyclohexyl)cyclohexane was treated with Mg and
      3,4,5-F3C6H2Br to give the bicyclohexane I.
 ST
      cyclohexane polycyclic prepn liq crystal
 IT
     Liquid crystals
         (procedure for the production of polycyclic compds.)
 IT
     83838-64-6P
                   142400-92-8P
                                  143361-58-4P
                                                  324754-79-2P
                                                                 477557-79-2P
     477557-80-5P 477557-84-9P
     RL: IMF (Industrial manufacture); SPN (Synthetic preparation); PREP
      (Preparation)
         (procedure for the production of polycyclic compds.)
     78-94-4, 3-Buten-2-one, reactions 110-91-8, Morpholine, reactions
     348-61-8, 1-Bromo-3,4-difluorobenzene
                                            593-60-2, Bromoethylene
     623-00-7, 4-Bromobenzonitrile
                                     40649-36-3, 4-Propylcyclohexanone
     46310-14-9, trans, trans-Bicyclohexane-4, 4'-diol
                                                       105942-08-3,
     4-Bromo-2-fluorobenzonitrile
                                    123843-67-4, 4-Bromo-2,6-
     difluorobenzonitrile
                            138526-69-9, 1-Bromo-3,4,5-trifluorobenzene
     477557-78-1
     RL: RCT (Reactant); RACT (Reactant or reagent)
         (procedure for the production of polycyclic compds.)
IT
     82254-86-2P
                   324754-77-0P
                                  326796-25-2P
                                                363619-23-2P
                                                                 477557-81-6P
     477557-82-7P
                    477557-83-8P
     RL: RCT (Reactant); SPN (Synthetic preparation); PREP (Preparation); RACT
     (Reactant or reagent)
        (procedure for the production of polycyclic compds.)
IT
     157453-53-7P
     RL: SPN (Synthetic preparation); PREP (Preparation)
        (procedure for the production of polycyclic compds.)
IT
     477557-84-9P
     RL: IMF (Industrial manufacture); SPN (Synthetic preparation); PREP
     (Preparation)
        (procedure for the production of polycyclic compds.)
RN
     477557-84-9 CAPLUS
CN
     Benzonitrile, 4-[(trans,trans)-4'-ethenyl[1,1'-bicyclohexyl]-4-yl]-2,6-
     difluoro- (9CI) (CA INDEX NAME)
```

Relative stereochemistry.